INTERMITIONAL SEARCH REPORT

International Application No

			101721 00700100
A. CLASSI IPC 7	FICATION OF SUBJECT MATTER C30B25/02 H01L21/205		
According to	o International Patent Classification (IPC) or to both national classific	ation and IPC	
	SEARCHED		
Minimum do IPC 7	comentation searched (classification system followed by classification C30B H01L	on symbols)	
	ion searched other than minimum documentation to the extent that a		
	ata base consulted during the International search (name of data ba , EPO-Internal	se and, where practical	, search terms used)
C. DOCUME	ENTS CONSIDERED TO BE RELEVANT		
Category *	Citation of document, with indication, where appropriate, of the rel	evant passages	Relevant to claim No.
X	BAUER M ET AL: "Relaxed Sige but thicknesses below 0.1 mum" THIN SOLID FILMS, ELSEVIER-SEQUOI LAUSANNE, CH, vol. 369, no. 1-2, July 2000 (200 pages 152-156, XP004200345 ISSN: 0040-6090 cited in the application page 153, left-hand column, paragrapage 154, left-hand column, line	(A S.A. 00-07), graph 2	18-22
X Furti	ner documents are listed in the continuation of box C.	χ Patent family	members are listed in annex.
"A" docume consid "E" earlier of filling d "L" docume which i citation "O" docume other n "P" docume later th	age int which may throw doubts on priority claim(s) or is cited to establish the publication date of another is or other special reason (as specified) ant referring to an oral disclosure, use, exhibition or nears ant published prior to the international filing date but an the priority date claimed	or priority data and died to understam invention "X" document of particular cannot be conside hyotive an inventiii "Y" document of particular cannot be conside document is combinent is combin the art. "8" document member	dished after the international filing date don't in conflict with the application but dithe principle or theory underlying the ular relevance; the claimed invention red novel or cannot be considered to ve step when the document is taken alone ular relevance; the claimed invention red to involve an inventive step when the step when the chained with one or more other such docuplination being obvious to a person skilled of the same palent family
	9 November 2003	27/11/2	the International search report
Name and r	naling address of the ISA European Patent Office, P.B. 5818 Patentiaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl, Fax: (+31-70) 340-3016	Authorized officer Wolff,	G

INTERINTIONAL SEARCH REPORT

International Application No
PCT/EP 03/03136

		PCI/EP 03/03136			
C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT Category © Citation of document, with indication, where appropriate, of the relevant passages Relevant to claim No.					
Caredout a	очания от сосыненя, міні винсенюя, мнеге арргорияла, от тів гоючалі развадев	Melevanii io ciam no.			
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Α .	ROSENBLAD C ET AL: "A plasma process for ultrafast deposition of SiGe graded buffer layers" APPLIED PHYSICS LETTERS, AMERICAN INSTITUTE OF PHYSICS. NEW YORK, US, vol. 76, no. 4, 24 January 2000 (2000-01-24), pages 427-429, XP002200819 ISSN: 0003-6951 page 427, right-hand column, paragraph 2 -page 428, left-hand column, last line	1-22			
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A	MUROTA J ET AL: "LOW-TEMPERATURE EPITAXIAL GROWTH OF SI/SI1-XGEX/SI HETEROSTRUCTURE BY CHEMICAL VAPOR DEPOSITION" JAPANESE JOURNAL OF APPLIED PHYSICS, PUBLICATION OFFICE JAPANESE JOURNAL OF APPLIED PHYSICS. TOKYO, JP, vol. 33, no. 4B, PART 1, 1 April 1994 (1994-04-01), pages 2290-2299, XP000595134 ISSN: 0021-4922 2. Ultraclean Low-Pressure CVD Processing; Figure 2	1-22			
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